TEGO[®] Wet 236

Superwetting surfactant for difficult-to-wet substrates offering good dynamic performance in waterborne printing inks





Struggling to print on films?

As the trend towards printing waterborne inks onto film substrates increases, so does the importance of finding a suitable wetting additive which enables high quality printing.

The challenge:

Not only do films have inherently lower surface energy compared to paper, they also frequently contain recycled content or must fulfill biodegradability requirements – lowering substrate quality. This, combined with increasing print speeds, can pose significant challenges to ink formulators.

The solution:

To ensure problem-free print runs with excellent results, the right substrate wetting additive is needed. Efficient dynamic and equilibrium surface tension reduction are key factors affecting performance. **TEGO**^{*} **Wet 236** offers a unique balance of dynamic and equilibrium surface tension reduction, making it our first choice for film substrates.







slow surfactant dynamic surfactant



Print Run Example: Waterborne flexographic ink on a compostable film



TEGO° Wet 236 compared to other Evonik substrate wetting additives

| PRODUCT | Static surface tension | Dynamic surface tension | Wetting on film |
|-----------------------------|------------------------|-------------------------|-----------------|
| TEGO [®] Twin 4100 | +++ | + | ++ |
| TEGO [®] Wet 236 | ++ | ++ | +++ |
| SURFYNOL [®] 420 | + | +++ | + |

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